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Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 10559-586002	Application No.
by A	closure Statement pplicant	Applicant	
(Use several si	heets if necessary)	Filing Date March 16, 2004	Group Art Unit

U.S. Patent Documents							
Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
Sw	. AA	4,848,141	07/1989	Oliver et al.		,	
	AB						
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	AĤ							
	AI							
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	Other Documents (include Author, Title, Date, and Place of Publication)				
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Sw	AK	P.T. Liu et al., Thin Solid Films 332 (1998) 345-350.			
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Examiner Signature	Date Considered
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